IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Kai SCHUMACHER, et al.

SERIAL NO: 10/524,037 GAU: 1793

FILED: February 9, 2005 EXAMINER: LIAO, DIANA J.

FOR: SILICON DIOXIDE DISPERSION

REQUEST FOR EXTENSION OF TIME UNDER 37 C.F.R. 1.136

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

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It i	is hereby requested that a three month extension of time be granted to November 5, 2009 for
	filing a response to the Official Action dated:
	responding to the requirements in the Notice of Allowability dated:
	filing the Formal Drawings. The Issue Fee due has been timely filed.
	responding to the Notice to File Missing Parts of Application dated:
	filing a Notice of Appeal. An Amendment After Final Rejection is being filed in lieu of a Notice of Appeal.
	filing an Appeal Brief. A Notice of Appeal was filed on:
	Applicant claims small entity status. See 37 CFR 1.27.
fil	ne required fee of \$1,110.00 is being made by credit card payment online (if electronically led), or is attached hereto (if paper filed), and any further charges may be made against the ttorney of Record's Deposit Account No. <u>15-0030</u> .

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, L.L.P.

Imbach

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